

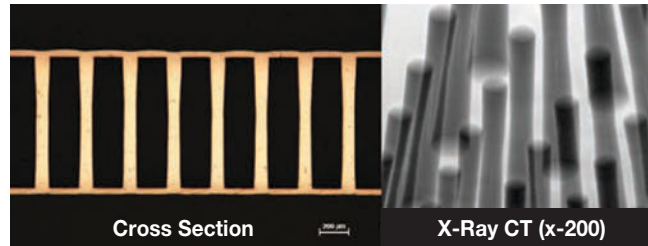
Key Substrate Processes

Additive for Copper Plating for Through-hole Filling

Thru-Cup EXP-01

- ▶ Electrolytic copper bath for Periodic Pulse Reverse
- ▶ Excellent filling performance for high aspect ratio through-hole
- ▶ Excellent metallurgical properties

2-step Plating (PPR + DC)



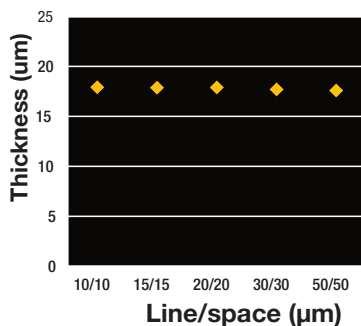
Through-hole Filling for Glass Panel

- ▶ Opening diameter: 100 μm ▶ Board thickness: 1000 μm ▶ Aspect ratio: 10:1
- ▶ Seed layer: MOSL + PEA V2 ▶ 1st electrolytic copper: EXP-01 (PPR)
- ▶ 2nd electrolytic copper: ETV-14 (DC)

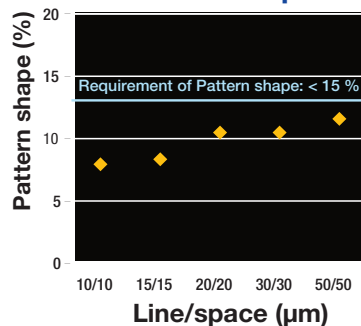
Electrolytic Copper RDL Plating Epithas EHK-12

- ▶ Excellent thickness distribution for fine pattern plating
- ▶ Excellent filling performance for blind via holes
- ▶ All process additives' concentrations can be easily analyzed by CVS

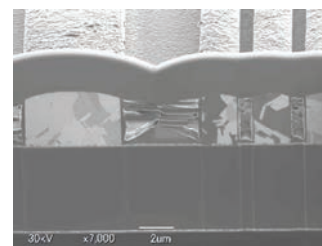
Thickness Distribution



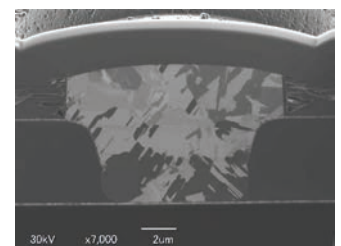
Pattern Shape



Pattern Plating on Fine Line



Minimum line/space: 1.6/1.4 μm
after seed etching



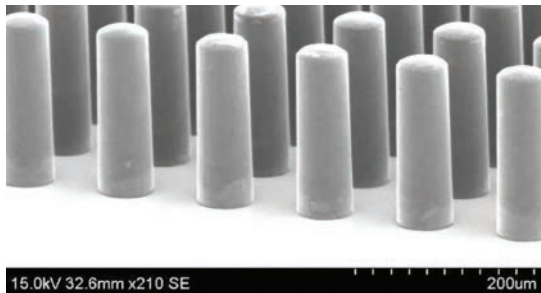
Blind via hole: 20 μm diameter
10 μm depth

Plating thickness: 3 μm on the surface by 1 A/dm²

Electrolytic Copper Post Plating

Epithas EPT-H

- ▶ Excellent flat shaped post using high speed plating.
- ▶ Bath aging has minimal impact
- ▶ Plating solution is easily controlled
- ▶ All process additives' concentrations can be easily analyzed by CVS

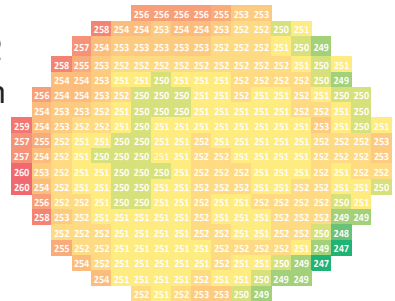


High Aspect Ratio Post Plating

- ▶ Current density: 9.3 A/dm²
- ▶ Post height target: 185 µm
- ▶ Plating time: 90 min
- ▶ Post diameter: 60 µm

Copper Post Plating for Wafers

- ▶ Wafer size: 300 µm
- ▶ Current density: 25 A/dm²
- ▶ Post height target: 250 µm
- ▶ Plating time: 45 min
- ▶ Post diameter: 200 µm

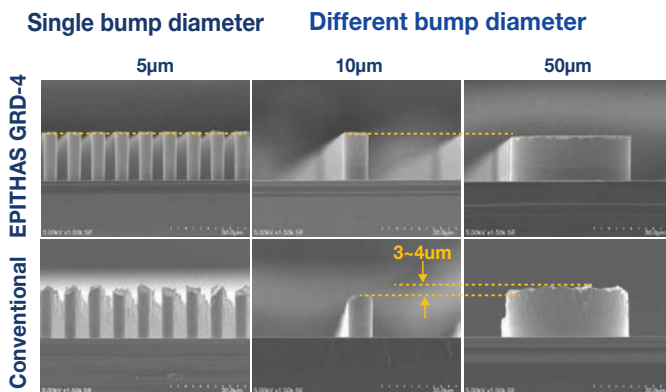


Total 100,000 posts
Post height uniformity
in Ø300 mm whole wafer

Sn-Ag Bump Forming

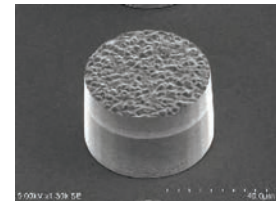
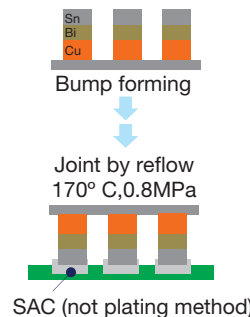
Epithas GRD-4

- ▶ Uniform Sn-Ag thickness with different diameters
- ▶ Smooth surface morphology

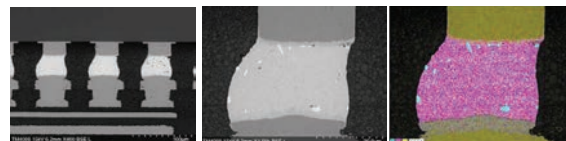


Sn-Bi Bump Forming for Low Temperature Soldering

- ▶ Solder joint at temperatures < 200° C



Cu/Bi/Sn thickness = 25µm/3µm/7µm
Bi/Sn = 25%/75%



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